

[本期目录](#) | [下期目录](#) | [过刊浏览](#) | [高级检索](#)[\[打印本页\]](#) [\[关闭\]](#)**论文****Si (100) 衬底上Mg_{0.33}Zn_{0.67}O薄膜的结构及光学性能**刘全生¹,张希艳²1. 长春理工大学
2. 长春理工大学材料科学与工程学院**摘要:**

采用射频磁控溅射法在Si (100) 衬底上制备了Mg_{0.33}Zn_{0.67}O薄膜, 研究了Mg_{0.33}Zn_{0.67}O薄膜的结构和光学性能。结果表明, Si (100) 衬底上Mg_{0.33}Zn_{0.67}O薄膜呈六方纤锌矿结构, 薄膜沿c方向取向生长, 且c轴方向晶格增大0.03nm。薄膜呈现优异的半导体特性, 激子吸收峰位于297nm, 禁带宽度为4.3eV。薄膜平均粒径约为20nm。薄膜在深紫外激发下的荧光发射位于368nm。

关键词: Mg_{0.33}Zn_{0.67}O 薄膜 射频磁控溅射 硅衬底 紫外发光**Structure and Optical Properties of Mg_{0.33}Zn_{0.67}O Film Deposited on Si (100) Substrate**

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Abstract:

Mg_{0.33}Zn_{0.67}O film was prepared on silicon (100) substrate by RF magnetron sputtering (RFMS) method. Structure and optical properties of Mg_{0.33}Zn_{0.67}O film were studied. Result indicates that Mg_{0.33}Zn_{0.67}O film deposited on Si substrate is hexagonal wurtzite structure. The growth orientation of the film is along c axis and the lattice of c axis orientation increases 0.03nm. The film is present superior semiconductor property. The absorption peak of exciton is at 297nm and the band gap of film is 4.3eV. The average grain diameter is about 20nm. The fluorescent emission peak is at 368nm under deep-ultraviolet excitation.

Keywords: Mg_{0.33}Zn_{0.67}O film RFMS silicon substrate ultraviolet luminescence

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